Flattening conduction and valence bands for interlayer excitons in a moiré MoS₂/WSe₂ heterobilayer

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We explore the flatness of conduction and valence bands of interlayer excitons in MoS_2/WSe_2 van der Waals heterobilayers, tuned by interlayer twist angle, pressure, and external electric field. We employ an efficient continuum model where the moiré pattern from lattice mismatch and/or twisting is represented by an equivalent mesoscopic periodic potential. We demonstrate that the mismatch moiré potential is too weak to produce significant flattening. Moreover, we draw attention to the fact that the quasi-particle effective masses around the Γ -point and the band flattening are *reduced* with twisting. As an alternative approach, we show (i) that reducing the interlayer distance by uniform vertical pressure can significantly increase the effective mass of the moiré hole, and (ii) that the moiré depth and its band flattening effects are strongly enhanced by accessible electric gating fields perpendicular to the heterobilayer, with resulting electron and hole effective masses increased by more than an order of magnitude leading to record-flat bands. These findings impose boundaries on the commonly generalized benefits of moiré twistronics, while also revealing alternate feasible routes to achieve truly flat electron and hole bands to carry us to strongly correlated excitonic phenomena on demand.

1 Introduction

The exciting report of superconductivity associated with flat bands in moiré twisted bilayer graphene ¹ opened the floodgates to inducing and tuning the strongly correlated states associated with flat bands by interlayer twisting. ^{2,3} Flat bands and the associated correlated states should have a strong effect on the properties of interlayer excitons in bilayer systems, and in this paper we investigate these effects. The interlayer excitons are bound electron-hole pairs with the electrons and holes confined in spatially separated layers. Thanks to the separation, interlayer excitons have much longer lifetimes than intralayer excitons which are formed from electrons and holes in the same layer. ⁴ In this paper, we investigate the effect of band flattening on interlayer excitons.

Twisted bilayer graphene is unsuitable for the purpose because of the need for an insulating barrier to separate the layers and confine the electrons and the holes to their respective layers. Such a barrier greatly reduces the effects of interlayer coupling, making the layers behave as if they were isolated. The isotropic band structure of the low energy states of graphene is then not sensitive to an interlayer twist angle. Recent progress in the fabrication of high-quality van der Waals stacked bilayers has extended twisting to other 2D materials, most notably the transition-metal dichalcogenides (TMDs). ^{5,6} A major advantage of TMDs here is that the two TMD layers can be different, forming a heterobilayer, and they can be chosen with a type-II interface. A type-II interface confines the electrons and the holes in separate layers with-

Twisting in bilayers creates a periodic moiré pattern characterized by regions with different local stacking registries. The moiré pattern yields potential landscapes for electrons and holes along the plane.⁸ As a result, the properties of the excitons can be broadly tuned by flattening the electron and hole bands and changing their moiré potentials, leading to intriguing possibilities for novel technology devices.^{7,9–12}

In homobilayers, moiré patterns occur only in twisted samples but in TMD heterobilayers, because of the incommensurability of the two different TMD lattices, moiré patterns are present even without twisting. Rotational alignment has been found to influence the interlayer coupling in homobilayers, ¹³ but for TMD heterobilayers, the role and possible tunability of interlayer coupling remain open questions.

In this paper, we investigate the electronic structure of electrons and holes in a moiré potential landscape for small interlayer twists, primarily in a MoS₂/WSe₂ van der Waals heterobilayer (vdWHB). We use an efficient continuum model parameterized from first principles. Curiously, we find that the moiré bands for electrons and holes *do not flatten with increasing twist angle*. On the contrary, the effective masses decrease as the twist angle grows.

As an alternative flattening strategy, we investigate the effect of vertical pressure on the bands, directly linked with the reduction of the interlayer distance. We find that pressure does enhance the strength of the moiré potential and results in larger effective masses. As a further strategy, we also investigate the effect of an external electric field from vertical gating. We find that strong electric fields significantly enhance the moiré potential depths for the electrons and holes. This leads to increases in the effective masses up to two orders of magnitude, and the associated bands

out need for an insulating spacer layer. This allows formation of long-lived interlayer excitons in a moiré environment. ⁷

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become ultra-flat.

2 Results and discussion

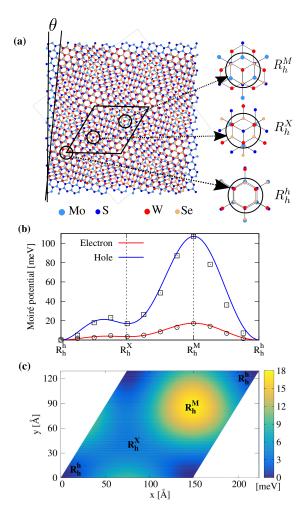


Fig. 1 (a) Sketch of a MoS₂/WSe₂ vdWHB with a small interlayer twist angle θ around zero, along with its moiré unit cell (black solid lines). Regions of local stacking registries R_h^h , R_h^X , and R_h^M are identified. (b) Conduction and valence band edges at the K-point from the moiré potential of an infinite aligned MoS₂/WSe₂ vdWHB. Vertical dotted lines emphasize different stacking registers. (c) Moiré potential for the electrons obtained from the continuum model.

We have used Density Functional Theory (DFT) to identify an optimal configuration of van der Waals heterobilayers. We searched for a heterobilayer with type-II band alignment and with the electrons and holes fully confined in their respective layers. We considered combinations of MoSe₂, MoS₂, WSe₂, WSe₂, from which we selected type-II MoS₂/WSe₂ vdWHB with the electrons (holes) fully confined to the MoS₂ (WSe₂) layer. ⁸ The band offsets are $\approx 220~(640)$ meV. $^{14-16}$

Figure 1a shows the crystal structure of a twisted MoS_2/WSe_2 vdWHB for a small angle θ centered on zero. The moiré unit cell is characterized by periodically alternating local stacking registries, identified as R_h^h , R_h^M , and R_h^X . Each stacking register exhibits different values for the energy of the conduction (valence) band minimum (maximum).

A further advantage of MoS₂/WSe₂ is that the other material

combinations yield valence band maxima (VBM) which for some stacking registries lie at the Γ -point. In contrast, for MoS₂/WSe₂ the gap is always at the K-point regardless of the stacking registry, so only states at the K-point are involved. ¹⁷

Since the band edges at the K-point are mostly composed of dorbitals of the metal atoms buried in between chalcogen atoms, the coupling between these band edge states in the two layers should not significantly change the interlayer band offsets. This allows us to consider the type-II interlayer exciton as the lowest energy case. Indeed, this is verified by DFT calculations of untwisted heterobilayers with different stacking orders, where band edges at the K-point are observed to be essentially superpositions of the monolayer bands. ¹⁸

Figures 1b and c show the effect of the moiré potential on the spatial evolution of the band edges for electrons and holes along the diagonal of the moiré unit cell in aligned MoS2/WSe2 vd-WHB. The band edges are obtained using a continuous model for the moiré potential (eqn (1) in Sec. 4.1) with DFT parameters $V_{e,1} = -17.3$ meV, $V_{h,1} = -107.1$ meV, $V_{e,2} = -13.8$ meV, and $V_{h,2} = -90.2$ meV. The energies are taken with respect to the minimum energy value corresponding to R_h^h where for this particular vdWHB MoS₂/WSe₂ both the electrons and holes would be trapped. The effect of the moiré pattern is much weaker for the electron bands than for the hole bands. This is because the VBM charge density extends to both layers giving rise to non-zero interlayer mixing, while the conduction band minimum (CBM) charge density is completely confined to the MoS₂ layer (Fig. 14 in Sec. 4.2). Thus, the VBM is modulated by the interlayer moiré potential, while the CBM responds to the intralayer moiré potential. Because the interlayer moiré potential is much deeper than the intralayer potential, the changes in the VBM charge density are more pronounced than those in the CBM.

In the following subsections, the electrons (holes) are always confined in their MoS₂ (WSe₂) layer, which allows us to take the same effective masses $m_{e(h)}=0.43~(0.35)m_0$ throughout. 15,16

2.1 Flattening the moiré band by twisting

Figures 2 and 3 show the band structure of moiré electrons and holes respectively, in the MoS_2/WSe_2 vdWHB along the k_x direction. The interlayer twist angles are $\theta=0.5^\circ$, 2° , and 3.5° . The Γ -point of the moiré Brillouin zone corresponds to the K-point of the Brillouin zone of the MoS_2 layer where the conduction band state is located. As the twist angle is increased, the period of the moiré pattern decreases, leading to larger and larger moiré Brillouin zones.

Figure 4 compares the lowest energy conduction (a) and valence band (b) for different twist angles. It is important to note that for small twist angles, bands may appear flat but this can be misleading. The apparent flatness is a result of a large anticrossing at the moiré band edge combined with the short Brillouin zone length. Properties of compact moiré interlayer excitons involve states with wavelengths exceeding the abbreviated first Brillouin zone, requiring states from the higher Brillouin zones within the unfolded zone scheme. Figs. 2 and 3 show that the reconstructed unfolded bands follow closely the bands of electrons and

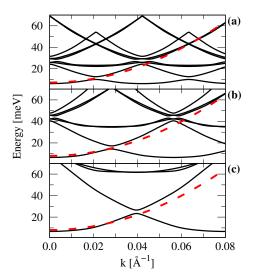


Fig. 2 Moiré bands for electrons in MoS $_2$ /WSe $_2$ vdWHB with interlayer twist angle (a) $\theta=0.5^\circ$, (b) 2.0° , and (c) 3.5° . Red dashed lines show for comparison a parabolic dispersion with electron effective mass $m_e=0.43m_0$ in an isolated MoS $_2$ layer.

holes in isolated layers, with their effective masses set at the K-point (red and blue dashed lines respectively). This means that these moiré quasi-particles behave similarly to the original electrons and holes in isolated layers, with no significant increase in the quasi-particle effective masses.

Figure 5 shows the properties that are conventionally used to characterize the flattening of bands, namely the ground state bandwidths, the bandgap between the lowest energy bands, and the effective masses at the Γ -point. With increasing twist angle, the electron and hole bandwidths and bandgaps increase (Fig. 5a and b). Fig. 5c shows that the electron effective mass is insensitive to twisting, but that the hole effective mass significantly decreases with twisting. This difference in behavior reflects the shallowness of the electron moiré potential relative to the hole moiré potential (Fig. 1b).

Band flatness is closely related to wave function localization. In terms of a tight-binding model of the moiré lattice, for a strongly localized wave function, the hopping between neighboring potential minima in the lattice will be small, resulting in flat bands. The moiré potential landscape of untwisted MoS_2/WSe_2 vdWHB is too shallow to produce very flattened bands. Twisting this heterobilayer only further suppresses the original moiré potential because it decreases the distance between the moiré potential minima (larger moiré Brillouin zone), leading to stronger hopping energies between adjacent unit cells. Thus as shown in Fig. 5, twisting works against flattening of the bands in this heterobilayer, in contrast to twisted homobilayers.

To work towards band flattening with large effective masses and energy gaps, one must identify ways to deepen the confining moiré potential. In what follows, we explore the deepening of moiré potentials through application of vertical pressure and electric fields.

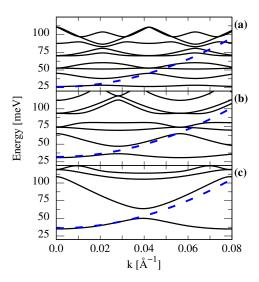


Fig. 3 Moiré bands for holes in MoS_2/WSe_2 vdWHB with interlayer twist angle (a) $\theta=0.5^\circ$, (b) 2.0° , and (c) 3.5° . Blue dashed lines show for comparison a parabolic dispersion with hole effective mass $m_h=0.35m_0$ in an isolated WSe $_2$ layer.

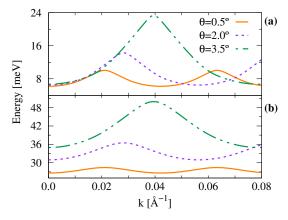


Fig. 4 Lowest energy moiré bands for (a) electrons and (b) holes in a MoS_2/WSe_2 vdWHB for different twist angles θ .

2.2 Flattening the moiré band by vertical pressure

As an alternative strategy, we now look at the effect on the bands of pressure applied perpendicularly and uniformly across the layers to reduce the interlayer distance d. Since the moiré potential is strongly affected by different interlayer couplings in the R_h^h , and R_h^X stacking regions, any decrease δd in the interlayer distance should efficiently control the depth of the moiré potential while leaving the moiré pattern unchanged.

The changes in the potential landscape due to the applied pressure are reflected in changes in the values of the parameters $V_{i,1}$ and $V_{i,2}$ in eqn (1). These determine the pressure-induced modifications on the band structures of the moiré electrons and holes in a MoS₂/WSe₂ vdWHB with the interlayer distance uniformly reduced in all regions by δd , up to $\delta d \sim 0.5$ Å. When $\delta d \sim 0.4$ - 0.5 Å, for a few stackings the bandgap becomes indirect. The value $\delta d = 0.5$ Å corresponds to an applied pressure ~ 9 GPa, well within the typical experimental range. ²⁰ Table 1 lists the values of the parameters for different values of δd .

Figure 6 shows the conduction band (a) and valence band (b)

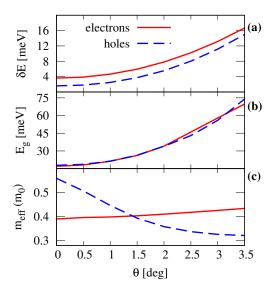


Fig. 5 (a) Ground-state bandwidths δE , (b) bandgap between the two lowest energy bands E_g , and (c) effective masses $m_{\rm eff}$ for electrons (red solid line) and holes (blue dashed line) in a MoS₂/WSe₂ vdWHB as a function of the twist angle θ .

Table 1 Parameters (in meV) for reconstructing moiré potentials for electrons and holes [eqn (1) in Sec. 4.1] under applied vertical pressure.

δd (Å)	$V_{e,1}$	$V_{e,2}$	$V_{h,1}$	$V_{h,2}$
0.0	-17.3	-13.8	-107.1	-90.2
0.2	-19.1	-19.6	-138.1	-137.2
0.4	-22.0	-24.4	-168.9	-199.2
0.5	-24.5	-28.5	-182.8	-237.4

edges along the diagonal of the moiré unit cell of MoS₂/WSe₂ vdWHB as a function of δd . The applied pressure enhances the interlayer coupling and this increases the depth of the moiré potential for R_h^X stacking. At $\delta d \sim 0.2$ Å, the lowest energy state switches from the R_h^h to the R_h^X stacking.

We see from Fig. 7 that, because of the switch, reducing the interlayer spacing has little effect on $m_{\rm eff}$ until $\delta d \sim 0.2$ Å. When $\delta d > 0.2$ Å, the hole moiré potential at R_h^X deepens to such an extent that, by $\delta d = 0.5$ Å, the moiré hole effective mass has increased by nearly an order of magnitude compared with its value in an isolated WSe₂ monolayer.

This is because the interlayer mixing of the VBM charge density significantly increases with decreasing interlayer distance. However, Fig. 6a shows for electrons that the variations in the moiré potential are small, and we see that the moiré electron effective mass does not change significantly with δd . Indeed, the CBM charge density is not expected to be sensitive to δd , since the conduction band states are strongly localized in the Mo atoms, buried in between the S atoms, which prevents electron states from undergoing significant modifications in the charge density due to the presence of another layer (Fig. 14a in Sec. 4.2). Valence band states, on the other hand, have their charge that also extends among the Se atoms, making them more susceptible to different interlayer distances and even to the stacking order (see Fig. 14b in Sec. 4.2).

We conclude that with applied uniform vertical pressure one

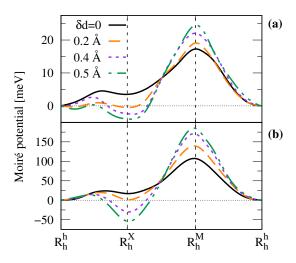


Fig. 6 (a) Conduction and (b) valence band edges at the K-point from the moiré potential of a MoS $_2$ /WSe $_2$ vdWHB with $\theta=0.5^\circ$, for decreases in the interlayer spacing $\delta d=0$ (black solid line), 0.2 Å (orange dashed), 0.4 Å (purple dotted), and 0.5 Å (green dash-dotted line).

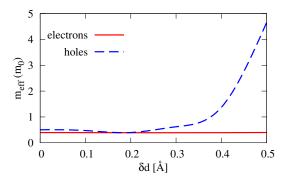


Fig. 7 Electron and hole effective masses $m_{\rm eff}$ in a MoS₂/WSe₂ vdWHB with $\theta=0.5^{\circ}$, as a function of the decrease δd in the interlayer spacing from vertical pressure.

obtains significant band flattening and an increase in the effective mass, but only for the valence band states.

2.3 Flattening the moiré band by vertical gating

As a final strategy, we investigate the effect on the bands of an external perpendicular electric field from gating. The electric dipole of interlayer excitons couples with the electric field E_z , and this will affect the moiré potential. From the Stark effect, the electric field E_z shifts the CBM and VBM energy levels in MoS₂ and WSe₂. An electric field applied from the MoS₂ layer to the WSe₂ layer should decrease the band gap. A field in the opposite direction would increase the gap, and for relatively small fields the electrons and/or holes can change layers. ¹⁰ The depth of the moiré potential landscape and the moiré effective masses can be readily increased and tuned by a field pointing from the MoS₂ to the WSe₂, since the R_h^h stacking region containing the minimum of the moiré potential has the largest interlayer distance, ^{8,9} and hence the largest dipole moment.

Figure 8 shows the conduction and valence band edges of the

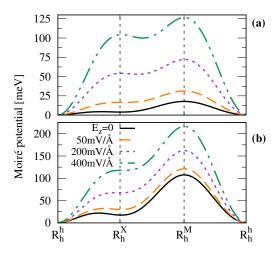


Fig. 8 Conduction and (b) valence band edges at the K-point from the moiré potential of MoS_2/WSe_2 vdWHB with $\theta=0.5^\circ$, for unbiased case (black solid line), and under applied perpendicular electric fields E_z of 50 mV/Å (orange dashed), 200 mV/Å (purple dotted), and 400 mV/Å (green dash-dotted line).

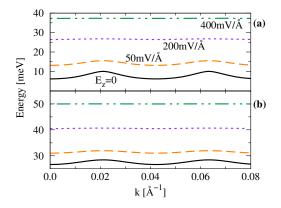


Fig. 9 Lowest energy moiré bands for (a) electrons and (b) holes in a MoS_2/WSe_2 vdWHB with $\theta=0.5^\circ$, for unbiased case (black solid line), and under applied perpendicular electric fields E_z of 50 mV/Å (orange dashed), 200 mV/Å (purple dotted), and 400 mV/Å (green dash-dotted line).

 MoS_2/WSe_2 vdWHB for different applied uniform electric fields. We find that the moiré potential indeed becomes progressively deeper with increasing E_z , while the R_h^h always remains the stacking with minimum energy. The deepening of the moiré potential is much larger than for the case with pressure (Fig. 6).

Figure 9 shows that with applied electric field, the lowest energy conduction band (a) and valence band (b) become remarkably flat. Fig. 10a shows bandwidths δE as small as $\sim 10^{-2}$ meV, the narrowest reported to date. Fig. 10b shows the corresponding energy bands E_g which increase by a factor of two, and Fig. 10c shows that there is a dramatic increase in both the electron and hole effective masses for vertical electric fields $E_z > 100$ mV/Å. The dramatic increase in the masses is severely curtailed when the twist angles are increased (inset Fig. 10), demonstrating once again the detrimental effects of twisting in this heterobilayer.

This is an exciting result, pointing to the possibility of achieving ultra-flat bands with associated strongly correlated interlayer

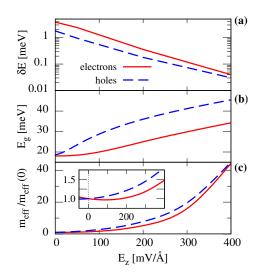


Fig. 10 (a) Ground-state bandwidths δE , (b) bandgap between the two lowest energy bands E_g , and (c) effective masses $m_{\rm eff}$ for electrons (red solid line) and holes (blue dashed line) in a MoS $_2$ /WSe $_2$ vdWHB with $\theta=0.5^\circ$ as a function of the applied perpendicular electric field E_z . For clarity, $m_{\rm eff}$ is scaled to the values for zero field $m_{\rm eff}(E_z=0)$. Inset in (c): $m_{\rm eff}/m_{\rm eff}(0)$ for $\theta=3.5^\circ$.

exciton states in MoS₂/WSe₂ vdWHB by means of an applied electric field, without need for twisting.

2.4 Effect of reconstruction of moiré lattice on band flattening

Recent experiments have reported lattice reconstruction upon relaxation of $MoSe_2/WSe_2$ heterobilayers with near-zero twist angles $\theta < 1^{\circ}.^{21,22}$ In this combination of materials, the formation energies of the R_h^M and R_h^X stacking registries are almost degenerate and significantly smaller than the R_h^h formation energy. Consequently, the regions of the original moiré pattern with these two stacking configurations expand and undergo reconstruction. In our MoS_2/WSe_2 heterobilayers, the formation energies exhibit the same features as $MoSe_2/WSe_2$ (Fig. 15a in Sec. 4.2). Therefore, we expect the lattice reconstruction at small twist angles would be similar.

As a consequence, the pattern of the electron and hole effective potentials would no longer be the original moiré pattern, depicted in Fig. 1c for electrons, but rather it would acquire a different form, as shown in Fig. 11a. The result would be a super-lattice composed of triangular domains with R_h^M or R_h^X registries with a strongly-reduced R_h^h region connecting the corners of the triangles. We assume there is no change in lattice parameters upon reconstruction, so the potentials in these regions will be nearly the same as shown in Fig. 1b.

Figure 12 shows, for electrons (red solid lines) and holes (blue dashed lines), the bandwidths δE (a), the corresponding band gaps E_g between the ground and first excited states (b), and the increase in both the electron and hole effective masses (c) as a function of the perpendicular electric field. At zero electric field, the narrow and shallow potential in the R_h^h region is not able to confine electron and hole wave functions. They are strongly lo-

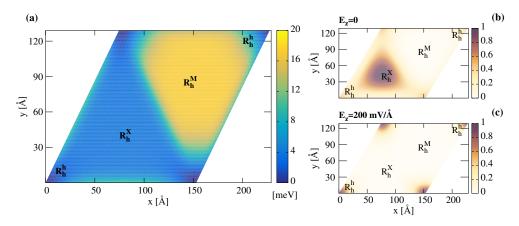


Fig. 11 (a) Moiré potential for the electrons in the reconstructed lattice of a MoS_2/WSe_2 vdWHB with sufficiently small twist angle. The potential in the vicinity of the confined R_h^h region is modeled by a Gaussian function of width d=15 Å. ²¹ Spatial distribution of the electron probability density for the reconstructed lattice, (b) in the absence of applied electric field, and (c) with perpendicular electric field 200 mV/Å.

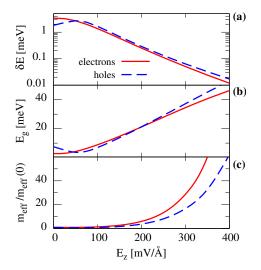


Fig. 12 After small angle lattice reconstruction in a MoS₂/WSe₂ vd-WHB, (a) ground-state bandwidths δE , (b) bandgap between the two lowest energy bands E_g , and (c) effective masses $m_{\rm eff}$ for electrons (red solid line) and holes (blue dashed line) as a function of the perpendicular electric field E_z . $m_{\rm eff}(0)$ is for zero electric field.

calized but within the triangular R_h^X patches (Fig. 11b). They exhibit small overlap with adjacent triangles, and consequently, the hopping parameters are small compared with the unreconstructed moiré potential. This leads to higher electron and hole effective masses in the reconstructed case.

In contrast to the unreconstructed case, here a weak electric field decreases very slightly the effective masses and the band flattening. This is because a weak electric field deepens the confinement potential in the R_h^h region, linking wave functions in the triangular R_h^X regions and thus increasing the overlap between wave functions in neighboring triangles. This leads to higher hopping parameters and hence less band flattening. However, except for weak fields, the deeper R_h^h potential will fully confine the electron and hole wave functions. The transition from wave functions confined in the triangular R_h^X regions at zero field to wave functions strongly confined in the R_h^h region is verified in the contour-

plots of the electron probability densities for zero and 200 mV/Å electric fields (Figs. 11b-c). This confinement again leads to a decrease in the hopping parameters and a significant flattening of the bands, just as in the unreconstructed case.

Figure 12c shows that for electrons (holes), the electric field still strongly increases the effective masses by a factor 60, decreases the bandwidths δE by 99.65% (99.86%), and increases the gaps E_g by a factor 10. We see that the dramatic increase of the effective masses with electric field and the associated submeV bandwidths are very similar to that for the unreconstructed moiré lattices reported in Sec. 2.3. Therefore the conclusions in the main manuscript about band flattening using applied electric fields remain equally valid in the presence of reconstruction.

2.5 Properties of interlayer excitons in moiré potential under band-flattening

Using the single-particle energy bands calculated in the previous sections, we now investigate the properties of the indirect excitons. Flattening the electron and hole bands directly tunes the properties of the interlayer excitons and their strongly-correlated phases. The exciton Rydberg energy $Ry^* = e^2/(4\pi\epsilon 2a_B^*)$, Bohr radius $a_B^* = \hbar^2 4\pi\epsilon/(\mu e^2)$, and binding energy E_b all depend on the effective reduced mass μ , which is increased when the bands flatten. These quantities are a measure of the strength of the electron-hole attraction, indicating the degree of difficulty of exciton dissociation 23 and the dissociation temperature $k_BT \propto E_b$. The binding energy also provides insight into the properties of the strongly correlated excitonic states, including the exciton superfluid. The Berezinskii-Kosterlitz-Thouless transition temperature for the superfluid is proportional to E_b . 25,26

We use a variational approach solving eqn (3) in Sec. 4.3 with the exciton wave-function modeled by an exponential. Fig. 13 shows the resulting exciton binding energy E_b and Bohr radius a_B^* as a function of (a) twist angle, (b) interlayer distance tuned by vertical pressure, and (c) applied electric field.

Figure 13a shows that with twisting, the moiré electron and hole masses have very limited tunability, so the exciton binding energy and Bohr radius do not greatly vary. For all the twist an-

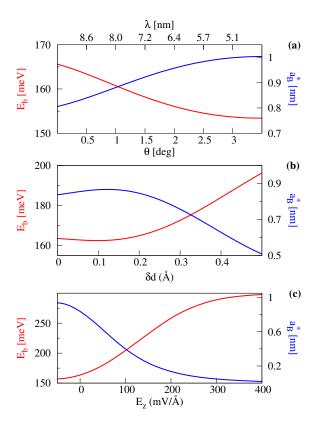


Fig. 13 Moiré interlayer exciton binding energy E_b and Bohr radius a_B^* in a MoS₂/WSe₂ vdWHB (a) as a function of twist angle θ (and the corresponding period of the moiré potential λ), (b) as a function of reduction of the interlayer distance δd upon pressure, and (c) as a function of a perpendicular electric field E_z .

gles, a_B^* remains an order of magnitude smaller than the moiré period λ (top x-axis). This indicates that twisting has little effect on the localization of the excitons. In contrast, Fig. 13b shows that if instead the interlayer distance is reduced by pressure, the binding energy increases by as much as 25% and the Bohr radius decreases by 50%.

The effect on the binding energy and Bohr radius is even more dramatic with application of a perpendicular electric field (Fig. 13c). The binding energy is enhanced by a factor of two for an increase in E_z from 0 to 400 mV/Å, while the Bohr radius drops by a factor of 100. Here the moiré period $\lambda \sim 8.6$ nm for $\theta = 0.5^\circ$, and the ratio of the effective Bohr radius to λ decreases with increasing the electric field. By $E_z = 400$ mV/Å where the bands are ultra-flat, a_B^* has decreased to two orders of magnitude less than λ . These results indicate extreme localized exciton states and a striking evolution towards strong correlations.

3 Conclusions

In summary, we have determined the moiré bands for electrons and holes in MoS_2/WSe_2 vdWHB with small interlayer twist angles near $\theta \sim 0^\circ$, to tune under twisting, pressure, or electric fields the flatness of the electron and hole bands, for the purpose of investigating interlayer excitons in the strongly correlated regime.

We have developed a continuum model parameterized from first principles, one that respects the crucial changes in the moiré potential from one stacking register to another. The method is readily adaptable for other material combinations of van der Waals heterobilayers, as well as for small twist angles near $\theta \sim 60^{\circ}.$ The method is robust and reliable and does not suffer from the computational limitations in first principle calculations of moiré heterostructures, imposed by the large number of atoms in the unit cell.

We first demonstrate for this heterobilayer that in the vicinity of the Γ -point, the moiré potentials in the presence of a small interlayer twist *do not* flatten the bands. This is opposite to the trend known for twisted bilayer graphene and expected for other homobilayers. Although when the twist angle increases from zero the bands are seemingly flatter within the shorter Brillouin zone, we find that in fact, the overall effective mass of the quasi-particles remains practically unchanged.

As an alternative idea for deepening the moiré potential, we considered reducing the interlayer spacing by application of uniform vertical pressure. This active manipulation was able to increase the effective mass of the hole by nearly an order of magnitude when the interlayer distance was decreased by 0.5 Å while, interestingly, the electron mass is left nearly unaltered. Such different behavior of electrons and holes bears nontrivial consequences on the resulting properties of the interlayer excitons, of crucial importance to any further exotic strongly-correlated excitonic phases in van der Waals heterobilayers.

We find that as an even more effective strategy, applying an electric gating field perpendicular to the heterobilayer can dramatically deepen the moiré potential, thereby leading to strong increases of the moiré electron and hole effective masses. Concretely, in MoS $_2$ /WSe $_2$ vdWHB with a 400 mV/Å electric field, the effective masses of the moiré electron and hole are both increased by a factor of ~ 40 . This makes the moiré bands ultra-flat, with bandwidths as narrow as 0.05 meV, the narrowest reported to date.

With such different yet complementary effects of these three manipulations, with their selective influences on electron and hole bands, and with the consequent tunability of the exciton binding energies and Bohr radii, we expect our results will help guide future works that seek strongly correlated electronic and excitonic phases in flat bands of 2D heterostructures.

4 Theoretical Methods

4.1 Continuous Model

We build our continuum model for the moiré potential using parameters extracted from the DFT calculations. The $C_{3\nu}$ symmetry of the potential landscape is imposed by assuming a moiré potential expressed as

$$V_i(\vec{r}) = V_{i,1}|f_1(\vec{r})|^2 + V_{i,2}|f_2(\vec{r})|^2, \tag{1}$$

with the index i=e(h) for electron (hole), $f_1(\vec{r})=(e^{-i\vec{K}\cdot\vec{r}}+e^{-i\hat{C}_3\vec{K}\cdot\vec{r}}+e^{-i\hat{C}_3\vec{K}\cdot\vec{r}})/3$, and $f_2(\vec{r})=[e^{-i\vec{K}\cdot\vec{r}}+e^{-i(\hat{C}_3\vec{K}\cdot\vec{r}+\theta_s)}]/3$. The \hat{C}_3 operator represents a 120° rotation, and $\theta_s=4\pi/3$.

To determine the band structures, we represent the Hamiltonian in a finite difference scheme, incorporating the 2D moiré potential landscape of eqn (1) and assuming periodic boundary conditions with a Bloch wave approach. The time independent Schrödinger equation is numerically solved separately for electrons and holes within the effective mass approximation.

4.2 Density Functional Theory calculations

The Density Functional Theory (DFT) calculations from first principles were performed using the Projector Augmented Wave (PAW) method ²⁷ implemented in the Vienna *Ab-initio* Simulation Package (VASP). ^{28,29} The generalized gradient approximation (GGA) from Perdew-Burke-Ernzerhof (PBE) is used for the exchange-correlation functional. ³⁰

We present details of DFT for untwisted MoS_2/WSe_2 vdWHB. The van der Waals interactions between the MoS_2 and WSe_2 monolayers were included by the dispersion-corrected density functional (DFT-D3) method. ³¹ A vacuum spacing of 18 Å is employed along the out-of-plane direction to model an isolated heterostructure. To limit the induced strain, an average of the experimentally measured lattice constants of bulk MoS_2 (3.160 Å) ³² and bulk WSe_2 (3.282 Å) ³³ is used as the in-plane lattice constant of the MoS_2/WSe_2 heterobilayer (3.221 Å) for all the stackings considered.

Structural relaxation was performed using the conjugate-gradient method until the absolute value of the components of forces on out-of-plane positions converged to within 0.005 eV/Å. During the structural relaxation across all the stackings, the inplane atomic positions were kept fixed. Further refinement of the model to incorporate lattice relaxation in a heterostructure is left as an outlook, but should not affect the main conclusions of the work. An energy cutoff of 450 eV, energy convergence threshold of 10^{-7} eV, and Γ -centered k-mesh of $15 \times 15 \times 1$ were used for structural relaxation and self-consistent calculations.

Six valence electrons were used in the PAW pseudo-potential, d^5s^1 for W/Mo and s^2p^4 for S/Se. Spin-orbit coupling was taken into account in all calculations except in structure relaxation. For each stacking, the MoS₂ and WSe₂ band edges are calculated at the K-point.

Figure 14 shows the wave-functions at the K-point of the conduction band minimum (CBM) and valence band maximum (VBM). The major contribution to the CBM charge density (panel (a)) comes from the d-orbital of the metal atom and is fully confined to the MoS₂ layer. The VBM charge density (panel (b)) has contributions both from the metal and chalcogenide atoms, and it extends out from the WSe₂ layer to give rise to a small but finite interlayer mixing (see inset).

Figure 15 shows for the different stackings, the variation in the total energy, the interlayer distances d, and the bandgap. We take d as the distance between Mo and W atoms (see inset). Fig. 15a shows that among all the sliding geometries explored, \mathbf{R}_h^M stacking is energetically the most favorable. Fig. 15b shows that the interlayer distance has a sensitivity to the stacking order of up to 0.6 Å. Uniform vertical pressure was modeled by reducing the interlayer distance by the same fixed amount across all the stackings without relaxation. Fig. 15c shows the evolution of the bandgap for the different stackings when the interlayer distance is reduced

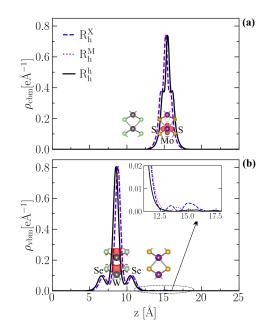


Fig. 14 Wave-function of (a) conduction band minimum and (b) valence band maximum states at the K-point, averaged along the perpendicular direction z, for untwisted MoS $_2$ /WSe $_2$ vdWHB. The isosurface plots shown in red are for a value 0.004 e/Å 3 at R_h^h stacking. Inset in panel (b) is a zoom-in showing the interlayer mixing.

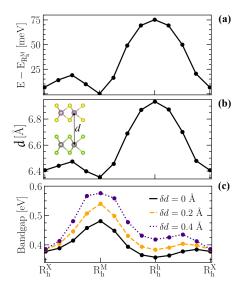


Fig. 15 (a) Variation of the total energy, (b) interlayer distance d, and (c) bandgap for the different stackings of aligned MoS $_2$ /WSe $_2$ vdWHB. In panel (a) the energy is relative to the energetically favorable stacking (R $_h^M$). In panel (c) δd is the reduction in the interlayer distance.

by δd .

4.3 Exciton binding energy in moiré potential

A Wannier-Mott exciton in the presence of the moiré potential is described within an effective mass approximation by a Hamiltonian that includes (i) separate kinetic energy terms, (ii) moiré potentials for each electron and hole (V_e and V_h , respectively),

and (iii) an electron-hole interaction term V_{eh} :

$$H_{ex} = -\frac{\hbar^2}{2M} \nabla_R^2 - \frac{\hbar^2}{2\mu} \nabla_r^2 + V_e (R + \frac{m_h}{M} r) + V_h (R - \frac{m_e}{M} r) + V_{eh} (r), \quad (2)$$

where r is the in-plane relative coordinate and R the center-of-mass coordinate of the electron-hole pair, and $M=m_e+m_h$ the total mass.

Unlike the system considered in Ref. Yu *et al.* 9 , in which the energy scale of the electron-hole binding is much larger than that of the moiré potential landscape, here the moiré potentials reach hundreds of meV and are of the same order of magnitude as the electron-hole interaction. With a deep moiré potential landscape, we assume that the moiré electron and hole band structures in isolated layers can be used to rewrite eqn (2) independent of R. The binding energy E_b of interlayer excitons in moiré potential is then obtained from

$$\left[-\frac{\hbar^2}{2\mu'} \nabla_r^2 + V_{eh}(r) \right] \psi(r) = E_b \psi(r). \tag{3}$$

The modified reduced mass μ' is determined from the moiré effective electron and hole masses. $V_{eh}(r)$ is the Keldysh potential for electrons and holes in different layers, ³⁴

$$V_{eh}(r) = \frac{e^2}{4\pi\varepsilon\varepsilon_0} \frac{\pi}{2r_0} \left[H_0\left(\frac{\sqrt{d^2 + r^2}}{r_0}\right) - Y_0\left(\frac{\sqrt{d^2 + r^2}}{r_0}\right) \right],$$
 (4)

where H_0 and Y_0 are respectively the Struve and Bessel functions of the second kind, and $r_0 = 2\pi\chi/\varepsilon$ is the screening length. $\chi \approx 7$ nm is the 2D polarizability of the medium, and $\varepsilon \approx 4$ the dielectric constant for a MoS₂/WSe₂ vdWHB embedded in hexagonal boron nitride. ³⁵ The exciton occupies the energetically most favorable registry stacking. In any case the dependence of E_b on the local register due to varying interlayer distances at the different registries, is expected to be weak because the associated variation in d is a tiny fraction of the exciton Bohr radius (Fig. 15b).

Author Contributions

Conceptualization: S.C., A.C., D.N., and M.V.M; Data curation: S.C.; Formal Analysis: S.C., A.C., and T.P.; Funding acquisition: S.C., A.C.; Investigation: S.C., A.C, L.C., D.N., and M.V.M.; Methodology: S.C., A.C., L.C., F.M.P., and M.V.M.; Project administration: M.V.M.; Resources: S.C., A.C., and T.P.; Software: S.C., A.C., and T. P.; Supervision: F.M.P., D.N., and M.V.M.; Validation: F.M.P., D.N., and M.V.M.; Visualization: S.C., and T.P.; Writing – original draft: S.C., A.C., and T.P.; Writing – review & editing: S.C., A.C., T.P., L.C., F.M.P., D.N., and M.V.M.

Conflicts of interest

The authors declare no conflict of interest.

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